OIPE.	IN THE UNITED STATES PATENT	Γ AND TRADEMARK OFFICE
L	licant: John Patrick Lemmon et al)
WE TRAD!	MAR) Group Art Unit:
Seri	al No.: 10/747,838)
	,) Examiner:
Filir	ng Date: 12/29/2003)
For:	1)
	Storage and Recovery)
)

INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR §§ 1.56, 1.97 AND 1.98

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450

Sir:

In compliance with the duty to disclose, submitted herewith is form PTO-A820 (PTO-1449) listing publication(s) of which those designated by 37 CFR § 1.56 are aware. Copies of the non-United States patents or published applications are enclosed.

The filing of this Information Disclosure Statement shall not be construed as a representation that a search has been made, or an admission that the information cited is, or is considered to be, material to patentability.

By:

Respectfully submitted,

CANTOR COLBURN LLP

David E. Rodrigues

Registration No. 50,604

Date: <u>April 16, 2004</u> Customer No. 23,413

(860) 286-2929

TRA	ANSMITTAL OI (U	Docket No. 133456-1					
1	In Re Application Of: John Patrick Lemmon et al						
C. TRAI	Serial No.	Filing Date 12/29/2003	Examiner	Group Art Unit			
Title: Comp							
		Commiss P.C	ddress to: sioner for Patents D. Box 1450 a, VA 22313-1450				
1. 🖾	 The Information Disclosure Statement submitted herewith is being filed within three months of the filing of a national application other than a continued prosecution application under 37 CFR 1.53(d); within three months of the date of entry of the national stage as set forth in 37 CFR 1.491 in an international application; before the mailing of a first Office Action on the merits, or before the mailing of a first Office Action after the filing of a request for continued examination under 37 CFR 1.114. 						
		37 (CFR 1.97(c)				
2. 🗆	2. The Information Disclosure Statement submitted herewith is being filed after the period specified in 37 CFR 1.97(b), provided that the Information Disclosure Statement is filed before the mailing date of a Final Action under 37 CFR 1.113, a Notice of Allowance under 37 CFR 1.311, or an Action that otherwise closes prosecution in the application, and is accompanied by one of:						
	☐ the statem	nent specified in 37 CFR 1.97(e)	<i>,</i> ;				
	OR						
	the fee set forth in 37 CFR 1.17(p).						

	OSURE STATEMENT 7(c))	Docket No. 133456-1					
In Re Application: Colohn Patrick Lemmon et al							
Filing Date Examiner Group Art Unit							
Compositions and Methods	Compositions and Methods For Hydrogen Storage and Recovery						
	•	ment of Fee ects to pay the fee set forth in 37 CFR 1.	47/11				
☐ The Director is hereby authorized to charge and credit Deposit Account No. 06-1130 as described below. ☐ Charge the amount of ☒ Credit any overpayment. ☒ Charge any additional fee required. Certificate of Transmission by Facsimile* Certificate of Mailing by First Class Mail I certify that this document and authorization to charge deposit account is being facsimile transmitted to the United States Patent and Trademark Office (F: (Date) Certificate of Mailing by First Class Mail I certify that this document and fee is being deposited on April 17, 2004 with the U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.							
	Signature	Signature of Person Ma. Michelle E. Fetzner	iling Correspondence				
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*This certificate may only be used if paying by David E. Rodrigues Registration No. 50,604 Customer No. 23, 413 Tel: (860) 286-2929							
cc.							

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		Docket Number (Optional)	Application Number
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